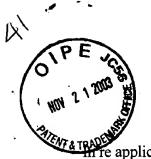
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PATENT APPLICATION

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

re application of

Docket No: Q60206

Toshiaki AOAI, et al.

Appln. No.: 09/620,708

Group Art Unit: 1752

Confirmation No.: 3362

Examiner: J. Chu

RECEIVED DEC 0'4 2003

TC 1700

Filed: July 20, 2000

POSITIVE PHOTORESIST COMPOSITION FOR FAR ULTRAVIOLET

EXPOSURE

PETITION FOR EXTENSION OF TIME UNDER 37 C.F.R. § 1.136

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Sir:

For:

Pursuant to 37 C.F.R. § 1.136, Applicant hereby petitions for an extension of time of three months, extending the time for responding to the Office Action of May 21, 2003 to November 21, 2003.

A check for the statutory fee of \$950.00 is attached. The USPTO is directed and authorized to charge all required fees, except for the Issue Fee and the Publication Fee, to Deposit Account No. 19-4880. Please also credit any overpayments to said Deposit Account. A duplicate copy of this sheet is enclosed.

Respectfully submitted,

Registration No. 41,441

Lee C. Wright

SUGHRUE MION, PLLC

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WASHINGTON OFFICE 23373
CUSTOMER NUMBER

Date: November 21, 2003

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950.00 DP